

RESEARCH ARTICLE

Ab initio study of boron-rich amorphous boron carbides

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Abstract

Amorphous boron carbide compositions having high B contents (B_xC_{1-x} , $0.50 \leq x \leq 0.95$) are systematically created by way of ab initio molecular dynamics calculations, and their structural, electrical, and mechanical characteristics are inclusively investigated. The coordination number of both B and C atoms increases progressively with increasing B/C ratio and more close-packed materials having pentagonal pyramid motifs form. An amorphous diamond-like local arrangement is found to be dominant up to 65% B content, and beyond this content, a mixed state of amorphous diamond- and B-like structures is perceived in the models because sp^3 hybridization around C atoms is still leading one for all compositions. The pentagonal pyramid motifs around C atoms are anticipated to appear beyond 65% content. The intericosahedral linear C–B–C chains do not form in any model. All amorphous boron carbides are semiconducting materials. The mechanical properties gradually increase with increasing B concentration, and some amorphous compositions are proposed to be hard materials on the basis of their Vickers hardness estimation.

KEYWORDS

amorphous, boron carbide, boron-rich, first-principles calculations, mechanical properties

1 | INTRODUCTION

Boron (B), carbon (C), or nitrogen (N) compounds form covalently bonded solids, and they are recognized as hard materials.¹ One of which is boron carbide^{2–4} and is a semiconducting system possessing a wide bandgap depending on the B-to-C stoichiometry.^{5,6} Boron carbide compounds are promising materials for several high-technology industries due to their distinguished features, such as good chemical inertness, high hardness, low wear coefficient, high melting point, and low density.^{7–12} Because of their unique electronic properties,^{8,13} they can have applications in photovoltaic and beta-voltaic devices,^{8,14} diodes and transistors,⁷ and neutron detectors^{15–19} as well. In addition, combining their attractive properties such as lightweight and high hardness, they can be also used in body armor applications.^{7,20,21}

The first boron carbide material was synthesized in 1858. However, it was not attained enough consideration until 1934.²² The stoichiometric ratio as B_4C was studied in the mid-1930s.²³ Up to date, boron carbide with different B/C ratios has been fabricated using numerous experimental procedures, such as plasma-enhanced chemical vapor deposition,²⁴ magnetron sputtering,^{3,4,25,26} pulsed laser deposition,^{27–29} ion beam synthesis,³⁰ hot pressing, and spark plasma sintering.^{31–33}

The atomic structure and mechanical characteristics of boron carbide materials appear to be relatively sensitive to B/C ratios. The studies proposed that B substitution first modified C atoms in the $B_{11}C$ icosahedra transforming $B_{11}C$ to B_{12} molecules, and then excess B atoms revised C–B–C chains.³¹ For the $B/C < 4$ materials, on the other hand, the existence of free C atoms in the microstructure and the formation of B_4C - and graphite-like structures

at a C concentration of >20 at.%. were suggested.³² As expected, the change in the local structure has obvious impacts on the mechanical properties of boron carbide. The maximum fracture toughness and hardness were observed for the stoichiometric composition (B_4C), and they surprisingly decreased for nonstoichiometric B_4C ($B/C > 4$ and $B/C < 4$) compositions.³⁴ For $B/C > 4$ materials, the decrease was attributed to the weakening of the bond strength (substitution of the stronger B–C bonds with weaker B–B bonds), whereas the decrease for $B/C < 4$ compositions was dedicated to free C atoms in the microstructure.³⁴

Amorphous state of boron carbides has also drawn attentions due to their unique properties and has been considered both experimentally and theoretically.^{15,35,36} An experimental investigation confirmed that pentagonal pyramids were the most preferable clusters in amorphous B_4C (a- B_4C).³⁵ The atomic and electronic behaviors of a- B_4C were investigated at the ab initio level using two different systems (containing 120 and 135 atoms), and several important findings were exposed. This computational study proposed that both amorphous configurations consisted of a random icosahedral network without linear chains, and a- B_4C owned a semimetal character.¹⁵ Later, the combination of experimental and theoretical studies provided valuable information regarding the local structure of a- $B_{2.5}C$ and revealed that it consisted of B_{12} , $B_{11}C$, and $B_{10}C_2$ icosahedrons.³⁶

Hydrogenated amorphous boron carbide films having several B/C ratios^{37,38} were also prepared. The basis of these studies is about their compositional, structural, physical, electrical–optical, and mechanical properties. a- $B_xC:H_y$ thin films ($3.4 \leq B/C \leq 4.9$ and H concentration changing from 10% to 45%) were fabricated via the PECVD technique, and they were found to have density from 0.9 to 2.3 g/cm³, Young's modulus from 10 to 340 GPa, and bandgap between 1.7 and 3.8 eV.³⁷ In a different investigation, a- $B_xC:H_y$ thin films ($3.4 \leq B/C \leq 4.9$ and H content varying from 37.5% to 50.5%) were synthesized by the PEVCD process, and it was proposed that the thin films had a good thermal conductivity (0.31 ± 0.03 W/(m K)) and the Young modulus of 12 ± 3 GPa.³⁸

Although there have been some investigations on the microstructure and mechanical descriptions of B-rich boron carbides, there is no elaborated information about the structural, electrical, and mechanical features of their amorphous form(s). In the current study, possible B-rich amorphous boron carbides with 10 different B/C ratios (B_xC_{1-x} , $0.50 \leq x \leq 0.95$) are modeled via ab initio molecular dynamics (MD) simulations, and some important properties (structural, electrical, and mechanical) are exposed in detail.

2 | COMPUTATIONAL METHOD

All calculations were executed by using the SIESTA ab initio code³⁹ within a pseudopotential method⁴⁰ and a generalized gradient approximation (GGA) proposed by Becke gradient exchange functional⁴¹ and Lee et al. correlation functional.⁴² A double-zeta was adopted as the atomic orbital basis set for the valence electrons. The grid mesh cutoff was set to 120 Ry, and the Γ -point sampling of k -mesh was applied for the Brillouin zone integration. The time step was selected as 1 femtosecond (fs). All simulations were done within the NPT (constant number of atoms, constant pressure, and constant temperature) ensemble. The controlling of temperature and pressure was managed by the velocity scaling and the Parrinello–Rahman⁴³ techniques, correspondingly. We used a BN melt consisting of 200 atoms as an initial structure and replaced all N atoms with C atoms. Later, the structure was equilibrated at 3400 K for 40 picoseconds (ps). To achieve a definite amount of B concentration (55%–95%), C atoms were randomly replaced by B atoms. Depending on B content, then each configuration was explored to 3400 K (50 at.% B) –2500 K (95 at.% B) for 40 ps in order to get a well-equilibrated melt, and then the melts were quenched to 300 K in ~ 155 –110 ps. Eventually, the resulting structures at 300 K were relaxed via a conjugate gradient technique until the maximum force was less than 0.02 eV/Å. In the present study, the density of c- B_4C is estimated to be about 2.45 g/cm³, fairly parallel to 2.52 g/cm³.³⁶ On the other hand, the density of amorphous materials ranges from ~ 1.97 to 2.24 g/cm³, less than 2.47 (± 0.01) g/cm³ reported for a- $B_{2.5}C$ in an experimental study.³⁶ The VESTA⁴⁴ program for the visualization of the random structures was used. Figure 1 reveals the ball stick demonstration of some selected amorphous arrangements.

3 | RESULTS

3.1 | Local structure

The partial pair distribution functions (PPDFs) investigation is one of the effective schemes to offer valuable descriptions about the characteristic of a structure at the atomistic level. Figure 2 shows the PPDFs of some amorphous boron carbide configurations. There are some notable changes in the distributions with changing B content as expected. As the B/C ratio increases, the intensity of the first and, similarly, second B–B peaks increases, due to the formation of more pentagonal pyramid-like motifs. For the B–C pairs, the intensity of the first peak moderately

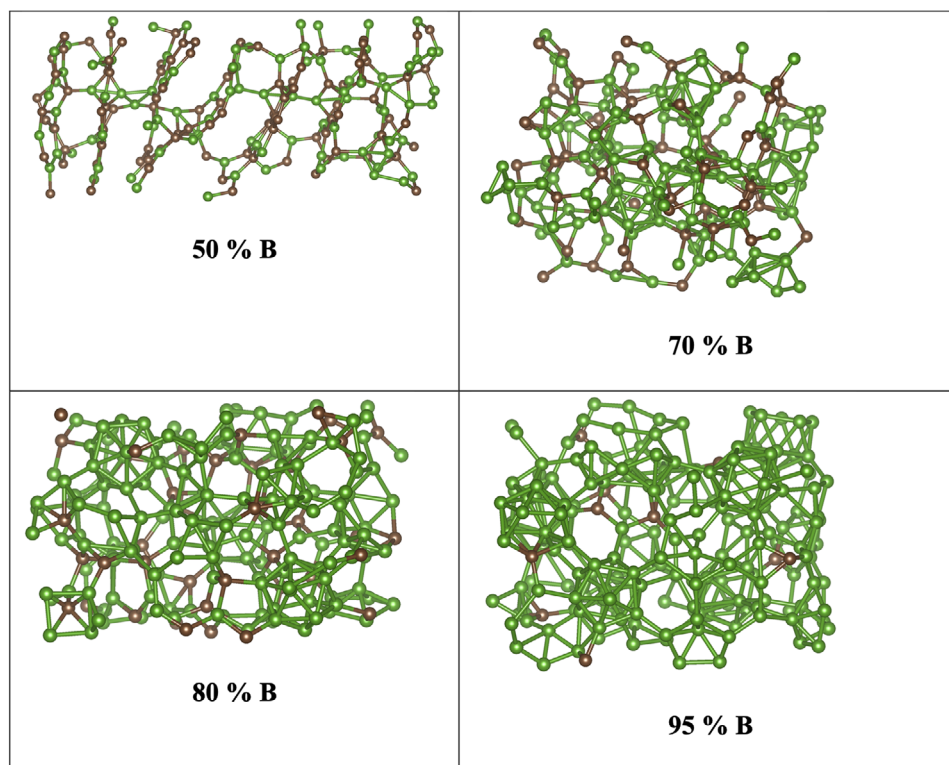


FIGURE 1 Ball stick representation of some amorphous models

decreases with increasing B content. C–C bonds exist only between 50% and 80% B concentrations.

The first peak position of PPDFs can be used to determine the mean bond separation for each pair. The average B–B bond length has the values of 1.75–1.77 Å, indicating that B content has almost no effect on this bonding. The range perceived is reasonably coherent with previously reported data of 1.75 Å in a-B_{2.5}C,³⁶ 1.74–1.80 Å in c-B₄C,⁴⁵ and 1.73–1.80 Å formed in the liquid, amorphous, and crystalline phases of B.^{46–48} The mean B–C bond distance is estimated to be 1.55–1.58 Å. Again, it appears that B content does not have a significant impact on this bonding as well. Our B–C estimations are also comparable with 1.57 Å in a-B_{2.5}C,³⁶ 1.64 Å in c-B₄C,⁴⁵ and 1.60 Å in c-B₁₃C₂.⁴⁹ The C–C bond distance is predicted to be in the range of 1.43–1.56 Å, which are comparable with 1.54 Å reported for a-B_{2.5}C,³⁶ 1.39–1.45 Å in c-B₄C,⁴⁵ 1.42 Å in graphite, and 1.54 Å in diamond.⁵⁰ Relative to the other separations, C–C bond seems to be sensitive to B content, which is probably correlated with the formation of different motifs (from threefold to sixfold coordinated) around C atoms having homopolar bonds.

In order to validate our results, we compare atomic structure factor $S(Q)$ and reduced pair distribution function $G_{PDF}(r)$ of two compositions [a-B₇₀C₃₀ and a-B₇₅C₂₅] with the neutron diffraction data of a-B_{2.5}C³⁶ and provide them in Figure 3. One can see that in spite of the small size

of simulation boxes and different composition ratios, our results fairly agree with the experiment.

The total and partial coordination numbers (CNs) are positively needed to shed some light onto the local structure of a material at the atomistic level, and hence, in the second step, we estimate them by way of cutoff distances (the first minimum) of PPDFs (2.04–2.33 Å for the B–B correlation, 2.10–2.17 Å for the B–C distribution and 1.91–2.07 Å for the C–C pairs depending upon B concentration). As shown in Figure 4, the average CN of B atoms increases continuously from 3.22 to 5.70, whereas that of C atoms changes steadily from 3.46 to 4.30. As we will discuss below, B atoms have a strong tendency to form sixfold-coordinated pentagonal pyramid-like motifs. As B content increases, more B atoms are able to form sixfold-coordination, and hence, the mean CN of B atoms gradually increases. We also see the development of pentagonal pyramid-like motifs around some C atoms (see the Voronoi analysis below) as in c-B₄C⁵¹ and a-B_{2.5}C.³⁶ Thus, such a development leads to high mean coordination for C atoms. We specifically focus on the 80% B content because it is a well-studied material and find the mean CN of a-B₄C to be 4.15, which is comparable with 4.66 in c-B₄C.

In order to have more knowledge on the atomic structure of the networks, the coordination distribution is considered and provided in Figure 5. As seen from the figure,

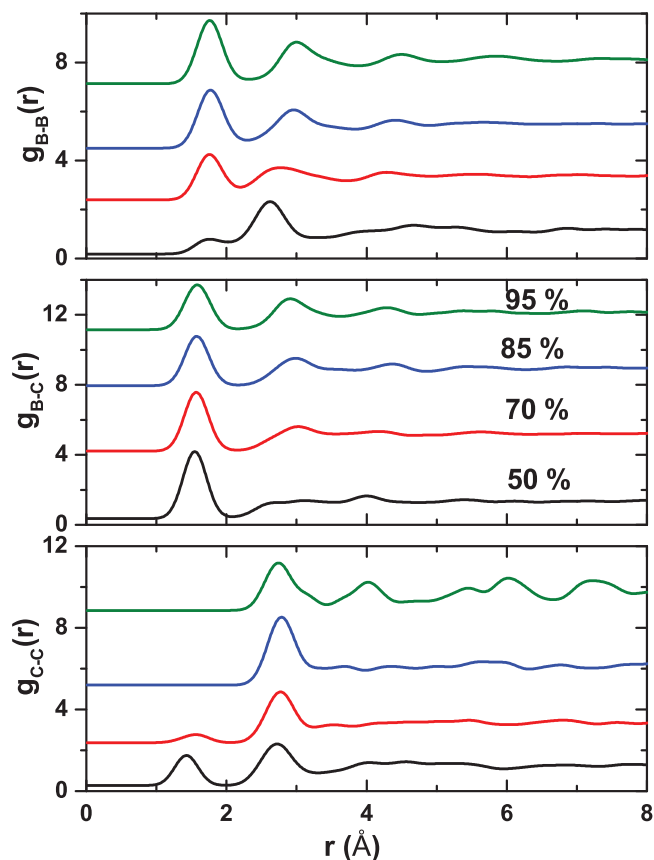


FIGURE 2 Partial pair distribution functions of some B concentrations

threefold-coordinated B atoms, supporting sp^2 hybridization, are prevailing at 50% B concentration and quickly decrease with increasing B content, whereas the sixfold-coordination rapidly increases. Fourfold-coordination, on the other hand, remains almost null up to 80% at which point it starts to decrease. Fivefold-coordination becomes noticeable at 60 at.% B and remains practically unchanged thereafter. Sevenfold-coordination develops at 65% B concentration, and its fraction reaches a maximum value of 17%. On the other side, for C atoms, threefold- and fourfold-coordinated structures with a fraction of 56% and 42%, respectively, are dominant at 50 at.% B. With the increase of B content, threefold-coordination decreases drastically, and parallel to this decrease, fourfold-coordination increases initially, remains nearly unaffected between 60% and 85% B contents, and then begins to decrease again. Fivefold-coordinated configuration gradually increases from 2% to 30%. Sixfold-coordinated motif first develops at 70% B content and reaches a maximum value of 10% at 90 at.% B.

The bond angle distribution function analysis is performed to provide further information on the microstructure of amorphous boron carbide configurations. Figure 6 shows the B–B–B, B–C–B, C–B–C, and C–C–C bond angle

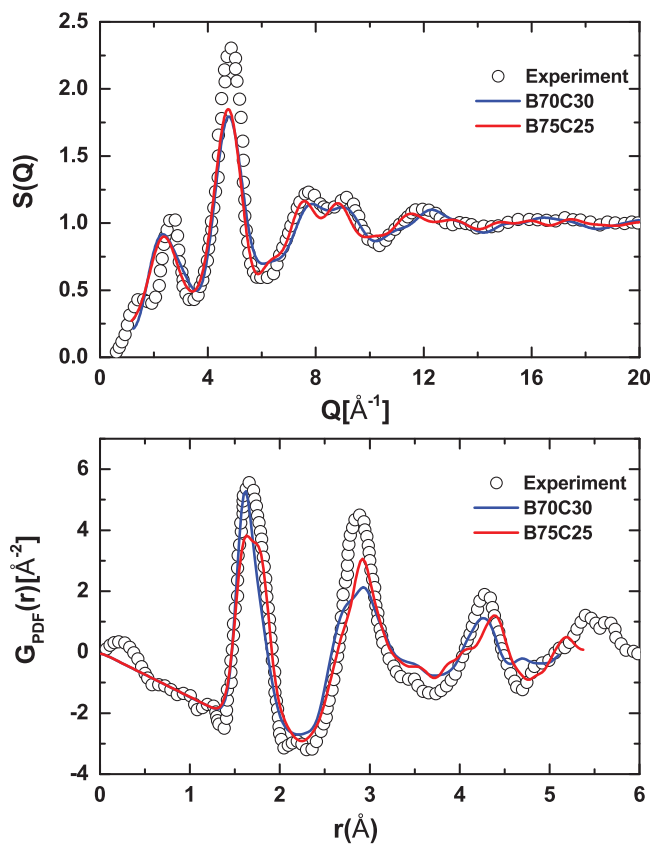


FIGURE 3 Comparison of atomic structure factor $S(Q)$ and reduced pair distribution function $G_{PDF}(r)$ of two compositions [a-B₇₀C₃₀ and a-B₇₅C₂₅] with the neutron diffraction data of a-B₂₅C. Source: The experimental data are extracted from Ref. [36]

distributions of some amorphous models. The B–B–B angles possess a wide distribution with several peaks ranging from roughly 56° to 122° because of twofold-to-fivefold structures, respectively, at 50% B concentration. From 70% to 95% B content, the distribution has two clear peaks at roughly 60° and 107° , which are indeed related to intra-icosahedral bonds of the pentagonal pyramids. The B–C–B angles show a broad distribution nearly from 62° to 148° owing to forming of the different types of C motifs between 50% and 65% B contents. After 70% B range, the first peak is placed at about 109° in view of tetrahedral angle, whereas the second peak is due to the B–C–B zigzag-like motifs, and it shifts from 114° to 121° with increasing B concentration. On the account of the existence of hexagonal angles in the disordered networks, the C–B–C distribution has a moderate peak at around 120° at 50%–70% B concentrations. With increasing B content, the main peaks are sharpened, especially at 95% B content, at nearly 115° and 128° , resulting from a structure like a bridge between incomplete pentagonal pyramids. The C–C–C angles of 50% B content possess two clear peaks at about 109° and 120° related to ideal tetragonal

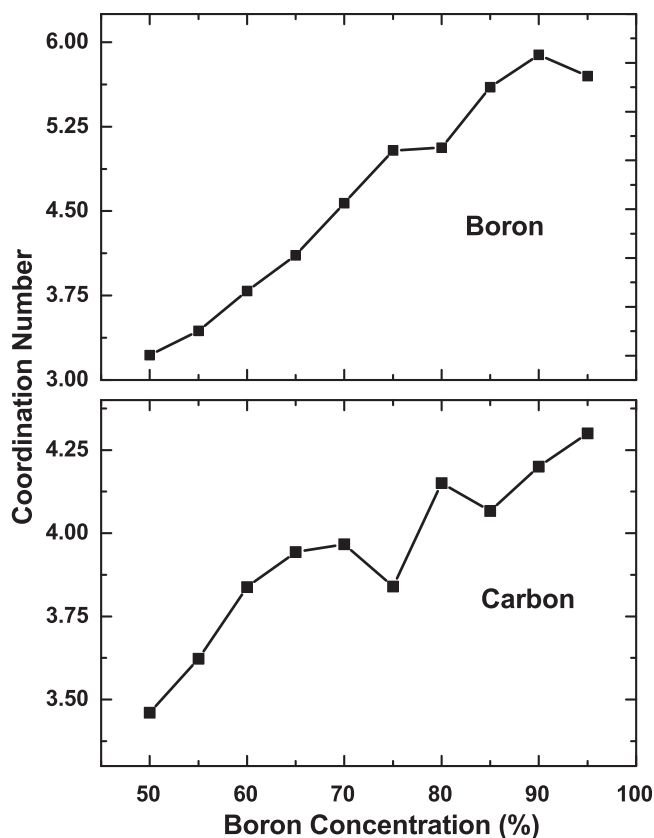


FIGURE 4 Modification of partial coordination numbers as a function of B concentration

and hexagonal angles, respectively. At 70% B concentration, there is a sharp peak at around 112° . The origin of this peak comes from the threefold-coordinated structure similar to zigzag shape formed by only three C atoms. And lastly, two apparent peaks of the C—C—C angle distribution function are placed at around 120° and 131° at 75% B content.

The Voronoi polyhedral method⁵² is a powerful tool to examine the kind of clusters formed around an atom. According to this approach, a polyhedron is notated via several Voronoi indices $\langle n_3, n_4, n_5, n_6 \rangle$, where n_i and $\sum n_i$ represent the number of i -edge faces of a cluster and its total CN, correspondingly. It is known that the main structure of ordered and disordered forms of B and B-rich materials consists of quasimolecular B_{12} icosahedron that involves ideal pentagonal pyramids. Consequently, in order to further understand the microstructure of the amorphous models as well as to define the geometrical structures, the Voronoi polyhedral approach is used. For this analysis, we concentrate mainly on $\langle 2,2,2,0 \rangle$ and $\langle 2,3,0,0 \rangle$ indices, presenting ideal and defective pentagonal pyramid-like geometries. Figure 7 displays their alternation as a function of B concentration. For B atoms, as the B concentration increases, the fraction of $\langle 2,2,2,0 \rangle$

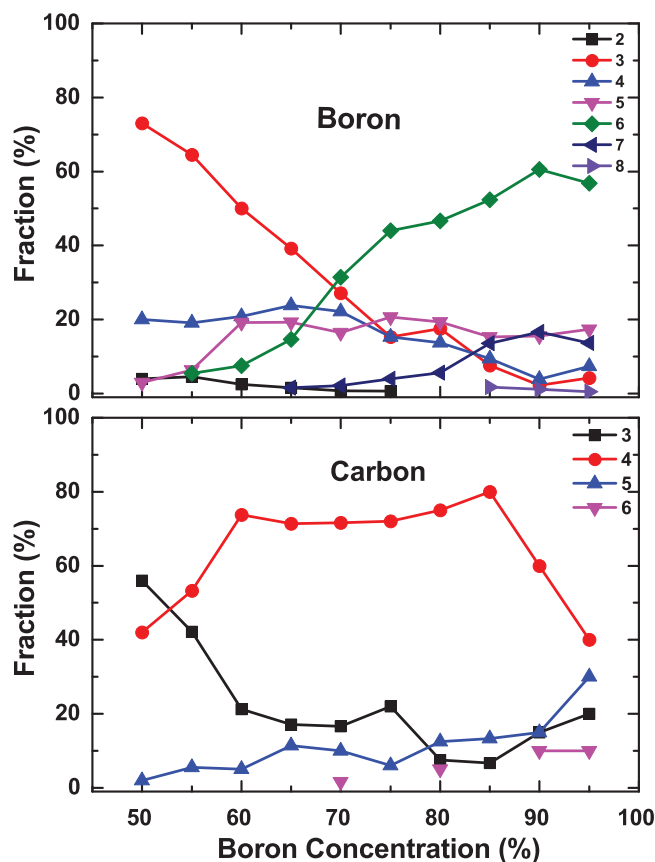


FIGURE 5 Coordination distribution of B and C atoms as a function of B concentration

type polyhedron raises from 5% to 55%. The frequency of $\langle 2,3,0,0 \rangle$ geometry alters from 3% to 16%. These analyses suggest that, as expected, the ideal and defective pentagonal pyramid-like geometries develop around B atom. As for C atoms, the frequency of $\langle 2,2,2,0 \rangle$ type motif begins to form at 70% B content, and its maximum fraction is 10%. The portion of $\langle 2,3,0,0 \rangle$ structure ranges from 2% to 30%. The examination discloses that some C atoms have a tendency to form pyramid-like structures in amorphous boron carbides as well.

3.2 | Electronic properties

B compounds might possess the electronic structure such that they can offer some potential applications such as diodes and thermocouple consisting transistors, and thus, the analyzing of electronic properties of amorphous networks generated is mandatory in this study. We first focus on $c\text{-B}_4\text{C}$ and found that its bandgap defined as a difference between HOMO and LUMO state is nearly 2.9 eV based on the GGA calculation (Figure 8), comparable well with 2.6–3.0 eV^{15,53–56} predicted in the earlier DFT-GGA/LDA

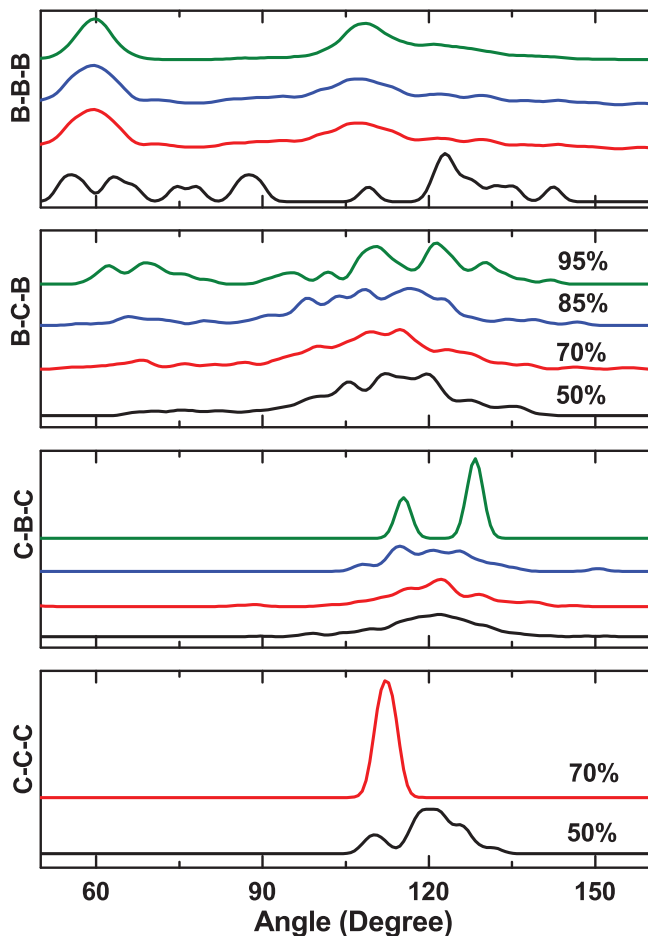


FIGURE 6 Bond angle distribution functions at some B concentrations

studies but less than 3.84 eV based on a DFT-hybrid exchange functional (HEF) calculation.⁵⁷ In order to estimate more accurate bandgap energy of the amorphous states, we perform GGA + U calculations by taking the DFT-HEF estimation as our reference. We change the Hubbard potential U (for B-p states because they are more dominant near the Fermi level for both valence and conduction bands) until the bandgap energy of c-B₄C is close to the DFT-HEF prediction of 3.84 eV.⁵⁷ We find that $U = 4.5$ eV (for B-p state) yields a bandgap of 3.85 eV for c-B₄C in our calculation, and the same U is used for all amorphous configurations. The forbidden bandgap of the amorphous models shows an increasing trend with increasing B content and is in the range of 0.2–1.47 eV as shown in Figure 8. It should be noted here that some mid-gap states near the Fermi level are observed for some amorphous configurations such that their bandgap is projected by ignoring them. Considering the disordered nature of the models, one can see that our predictions are objectively comparable with the values of 0.77–1.80 eV in the crystals with B/C = 2.4–50.⁵⁸

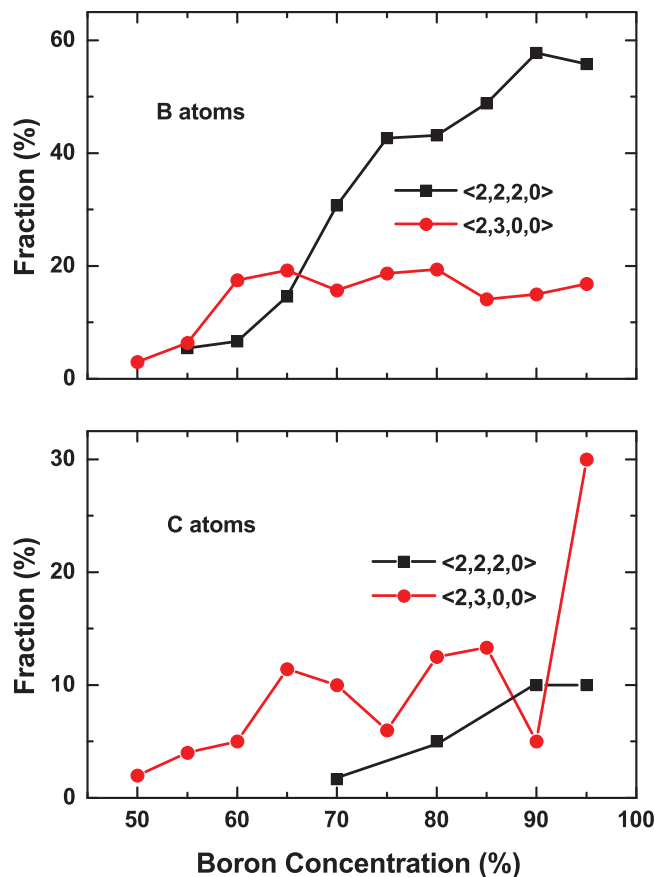


FIGURE 7 Fraction of ideal (<2,2,2,0>) and defective (<2,3,0,0>) pentagonal pyramids

3.3 | Mechanical properties

The mechanical descriptions, including the bulk modulus, Poisson's ratio, Young modulus, shear modulus, Vickers hardness, and Pugh's ratio, are vital to the applications of a material in technology. Therefore, the mechanical features of the amorphous models are inclusively investigated. For comparison purposes, Table 1 gives the mechanical properties of some B concentrations in this study along with the data of some related crystal and amorphous materials in the literature.

The bulk moduli (K), the compressibility of a material under pressure, are calculated by fitting the energy–volume relation of each model to the third-order Birch–Murnaghan equation of states:

$$E(V) = E_0 + \frac{9V_0K}{16} \left\{ \left[\left(\frac{V_0}{V} \right)^{2/3} - 1 \right]^3 K' + \left[\left(\frac{V_0}{V} \right)^{2/3} - 1 \right]^2 \left[6 - 4 \left(\frac{V_0}{V} \right)^{2/3} \right] \right\} \quad (1)$$

TABLE 1 The mechanical properties of some B concentrations in this study along with the data of some crystal and amorphous materials in the literature

	<i>K</i> (GPa)	<i>E</i> (GPa)	μ (GPa)	ν	<i>H</i> (GPa)	References
a-B₅₀C₅₀	105	142	56	0.27	~7–9	This study
g-graphite	38			0.28		59
		23–32	10–13		~2–3	67
Graphite				0.27		70
Amorphous C ^a		40–145		0.25	~5–15	68
a-B₈₀C₂₀	170	288	120	0.22	~18	69
a-B ₄ C		255–351			~21–34	This study
c-B ₄ C	245	470	200	0.17	~30–32	71
c-B ₄ C	248–274	441–472	188–200	0.17–0.18	~45	This study
					~42	51, 61–64, 73, 78
a-B₈₅C₁₅	193	326	135	0.21	~20	63
c-B ₈₅ C ₁₅			195–197	0.17		71
	245	466	197	0.18		62
a-B₉₀C₁₀	199	370	155	0.19	~23–25	65
c-B ₉₀ C ₁₀	130–183	319–348		0.16–0.21		This study
	170–194	323–348	132–150	0.16–0.22		62
a-B₉₅C₅	183	332	139	0.20	~20–23	65
a-B		320				This study
γ -B	224		236	0.11		72
						66

Abbreviation: g-graphite, glassy graphite.

^aWith different sp³/sp² ratios.

where *E* and *E*₀ stand for the energy and the equilibrium energy, correspondingly, whereas *V* and *V*₀ represent the volume and the equilibrium volume, respectively. *K*' is the derivative of *K* with respect to pressure ($K' = dK/dP$). Figure 9 represents the change in *K* as a function of B content. As can be seen from the figure, it gradually increases. a-B₅₀C₅₀ has a value of nearly 105 GPa. The comparison with glassy graphite (g-graphite) (*K* = 38 GPa)⁵⁹ suggests that a-B₅₀C₅₀ shows better incompressibility relative to g-graphite, but it is considerably less than 363 GPa in the diamond-like amorphous carbon.⁶⁰ For c-B₄C, our estimation is 245 GPa, comparable with the previous data of 248–274 GPa.^{51,61–64} On the other hand, its amorphous form has a value of 170 GPa, suggesting a noticeable softening by amorphization. Similar trend is also observed for 85% B concentration; namely, the bulk modulus of a-B₈₅C₁₅ (*K* = 193 GPa) is again smaller than 245 GPa in its crystalline form.⁶⁵ The *K* value of a-B₉₀C₁₀, about 199 GPa, is larger than 130–183⁶² and 170–194 GPa⁶⁵ in its crystalline counterpart. For a-B₉₅C₅, it is computed to be nearly 183 GPa. Because there is no data available in the literature for this composition, we compare it with a crystalline B phase (γ -B), the *K* of which is 224 GPa.⁶⁶ One can see that amorphization causes a visible decrease in bulk modulus.

Poisson's ratio (ν), described as the ratio of transverse strain to longitudinal strain computed by the application of a uniaxial strain along the principal axes, is estimated using the following equation:

$$\nu_{ij} = -\frac{\Delta L_i/L_i}{\Delta L_j/L_j} \quad (2)$$

where *L*_{*s*} are the magnitude of the supercell's vectors, and *i* and *j* represent the principal (*x*, *y*, and *z*) directions. As shown in Figure 9, ν decreases with increasing B content and lies in the range of nearly 0.27–0.20. For a-B₅₀C₅₀, it is found to be roughly 0.27, which rather well overlaps with 0.28, 0.27, and 0.25 reported for g-graphite, graphite, and amorphous carbon with different sp³/sp² ratios,^{67–69} respectively. For c-B₄C, our calculation is 0.17, quite coherent with the experimental data of 0.17 and 0.18.^{61–63} On the other side, for a-B₄C, ν is about 0.22 and slightly higher than that of c-B₄C^{61–63} due to its amorphous nature. ν is 0.21 for a-B₈₅C₁₅, whereas its crystalline counterpart has the values of 0.17–0.18.^{62,65} For a-B₉₀C₁₀, the ratio is about 0.19, parallel to 0.16–0.22 in c-B₉₀C₁₀.^{62,65}

Young modulus (*E*), in other words, elastic modulus, stiffness of the material, is characterized with relationship

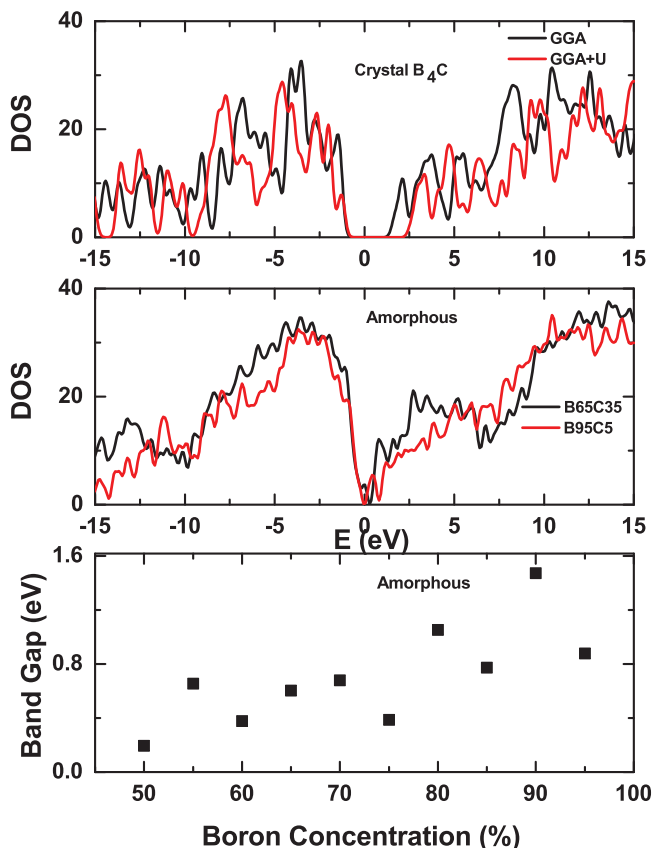


FIGURE 8 The bandgap energy of B_4C crystal (top panel). The bandgap energy of amorphous forms of $B_{65}C_{35}$ and $B_{95}C_5$ (middle panel). Variation of bandgap energy of amorphous materials as a function of B content (bottom panel)

between stress and strain in a material under a uniaxial deformation. E is related to both K and ν values and is practically obtained by the way of the following equation:

$$E = 3K(1 - 2\nu) \quad (3)$$

The Young modulus computed increases gradually from about 140 to 370 GPa with increasing B content as seen in Figure 10. For a- $B_{50}C_{50}$, E is projected to be about 142 GPa, whereas it is 23–32 GPa for g-graphite,⁷⁰ meaning that this material is more stiffer than g-graphite. However, in an earlier study on amorphous carbon with different sp^3/sp^2 ratios,⁶⁹ E is reported as 40–145 GPa, which is parallel to our result for a- $B_{50}C_{50}$. For c- B_4C , E is estimated to be 470 GPa, and it is pretty akin to the previously reported values of 441–472 GPa.^{61,62,73,78} E is nearly 288 GPa in a- B_4C , and it is comparable with experimental values of 255–351 GPa in a- B_4C .⁷¹ When a- $B_{85}C_{15}$ is concerned, E is about 326 GPa, noticeably less than 466 GPa⁶⁶ in its crystalline form. a- $B_{90}C_{10}$ has the highest value of 370 GPa, as seen in Table 1, in a good agreement with 319–348⁶² and 323–348 GPa⁶⁵ in c- $B_{90}C_{10}$. E is \sim 332 GPa for a- $B_{95}C_5$, which

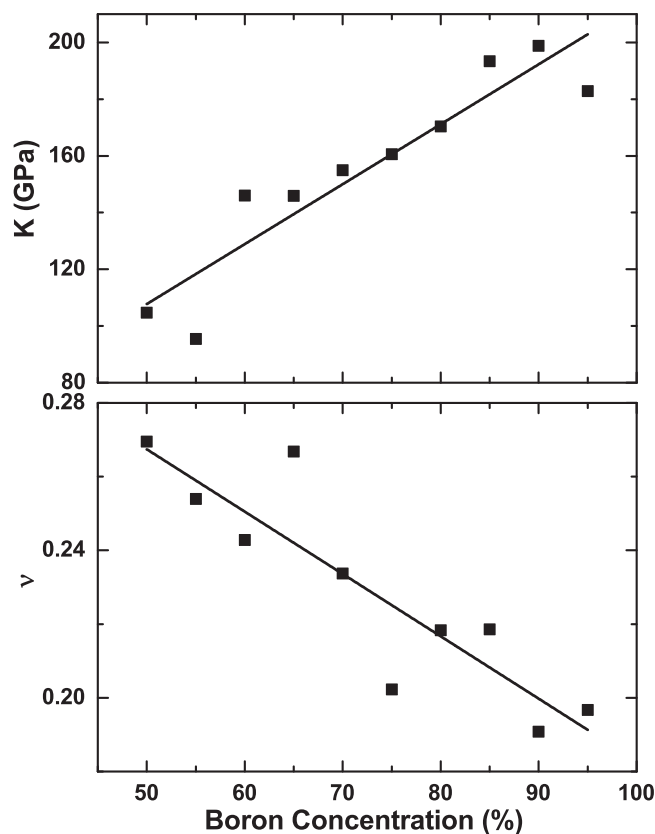


FIGURE 9 Variation of Bulk modulus (K) and Poisson's ratio (ν) as a function of B content

is close to the experimental measurement of 320 GPa in a-B.⁷² Eventually, the higher the B content, the stiffer the amorphous material forms.

Shear modulus (μ), the ability to resist shear deformation, can be defined as the ratio of shear stress to the shear strain of the material within the restricted elastic deformation and can be achieved by using the following definition:

$$\mu = \frac{E}{2(1 + \nu)} \quad (4)$$

As can be seen from Figure 10, μ exhibits a similar behavior with K and E . With increasing B content, μ progressively changes from \sim 56 to 155 GPa. For a- $B_{50}C_{50}$, μ is computed as 56 GPa, which is quite higher than 10–13 GPa in g-graphite,⁷⁰ implying that it shows more resistance to shear deformation, relative to g-graphite. The calculated μ of a- B_4C is about 120 GPa, whereas the estimated μ value for c- B_4C is nearly 200 GPa. Our results, especially for crystalline form, are rather close to the previous results of about 188–200 GPa.^{61,62,73} Similarly, a noticeable decrease in μ is observed for $B_{85}C_{15}$ composition: It is about 135 GPa in a- $B_{85}C_{15}$ and 195–197 GPa in c- $B_{85}C_{15}$.^{62,65} On the other hand, μ is projected as 155 GPa for a- $B_{90}C_{10}$, comparable with

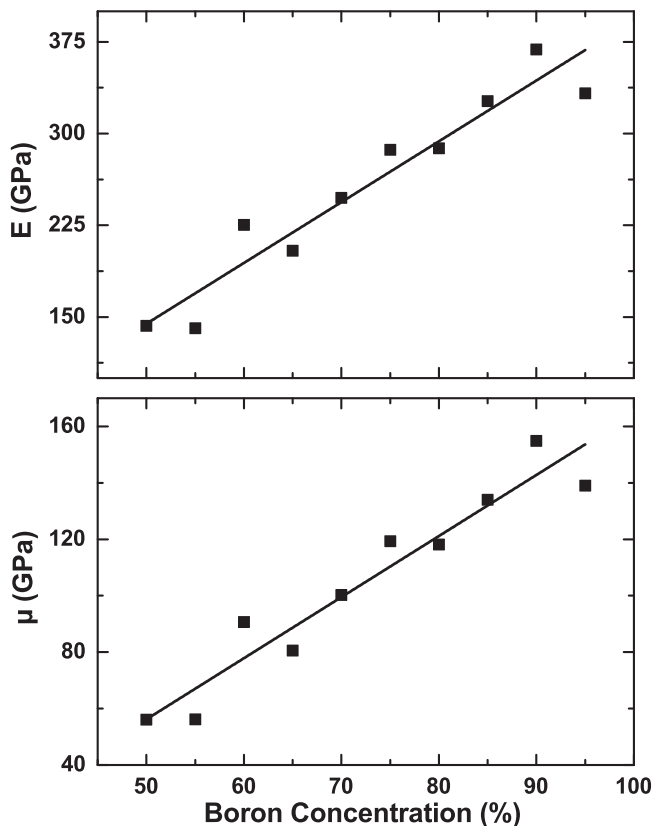


FIGURE 10 Variation of Young's modulus (E) and shear modulus (μ) as a function of B content

132–150 GPa in $c\text{-B}_{90}\text{C}_{10}$.⁶⁵ Consequently, one can see that the estimated μ values are roughly equal to or less than that of their crystalline counterparts.

Vickers hardness (H_v), a measure of the resistance of a material to deformation, can be useful to determine the correlation between hardness and elastic properties. H_v can be approximately projected by different practical correlations related to various mechanical properties of a material such as μ and E ^{74–77}:

$$H_v = 0.151\mu \quad (5)$$

$$H_v = 2\left(\frac{\mu}{n^2}\right)^{0.585} - 3 \text{ (GPa)} \quad (6)$$

$$H_v = 0.92\left(\frac{1}{n}\right)^{1.137} (\mu)^{0.708} \quad (7)$$

$$H_v = 0.0635E \quad (8)$$

The alteration of the hardness is illustrated in Figure 11, and it rises from ~ 7 to 25 GPa with increasing B concentration. The computed H_v value for $a\text{-B}_{50}\text{C}_{50}$ is in the range of 7–9 GPa, as given in Table 1, apparently higher than 2–3 GPa in $g\text{-graphite}$ ⁷⁰ but relatively closer to 5–15 GPa in amorphous carbon having different sp^3/sp^2 ratios.⁶⁹ H_v is projected to be 18 GPa for $a\text{-B}_4\text{C}$, whereas it is reported

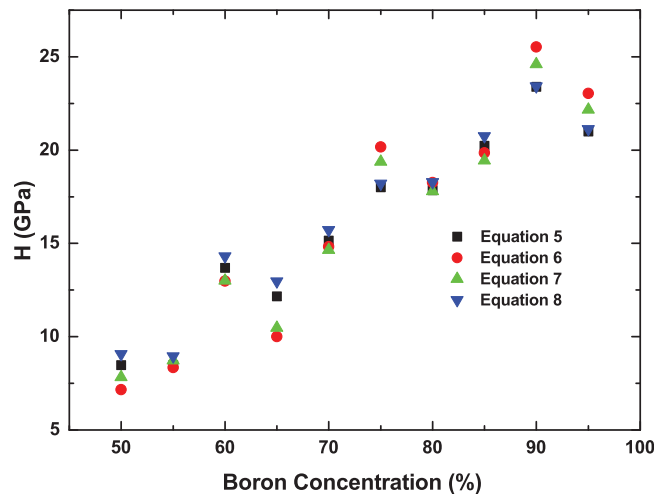


FIGURE 11 Variation of Vickers hardness (H_v) as a function of B content

to be between 20.8 and 33.8 GPa for $a\text{-B}_4\text{C}$ depending on the deposition temperature (25–900°C).⁷¹ Accordingly, one can see that our estimation is fairly comparable with the lower limit of the experiment. For its crystalline counterpart, the reported values of 42–45 GPa^{61,73,78} are slightly higher than our predictions of ~ 30 –32 GPa. The materials beyond 70% B content have hardness, higher than 20 GPa, indicating that these disordered structures can serve as hard materials.

Pugh's ratio ($n = \mu/K$) is a method propounded by Lewandowski⁷⁹ to designate whether a material is brittle or ductile by using other mechanical properties. According to this method, if μ/K is higher (or lower) than 0.41–0.43, then material is called as brittle (or ductile). On the other way, ν can be also used to define ductile versus brittle nature of materials, and ν value is lower (higher) than 0.31–0.32 is considered to be brittle (ductile). In the last part, the Pugh ratio is calculated and presented in Figure 12. The computed Pugh ratio is in the range of 0.53–0.77, indicating that all amorphous models are brittle in nature. Besides, ν values also support this finding.

4 | DISCUSSION

$a\text{-B}_{50}\text{C}_{50}$ exhibits a mixed state of sp^2 and sp^3 hybridizations. Its sp^3/sp^2 ratio is about 61%, and hence, we believe that $a\text{-B}_{50}\text{C}_{50}$ is structurally close to the low-density amorphous diamond. Indeed, the materials up to 65% B content carry essentially the characteristic of amorphous diamond-like structure, but it is slightly softer than amorphous diamond-like structure when its mechanical properties are considered, which is probably associated with the presence of weaker B–B or B–C bonds in boron

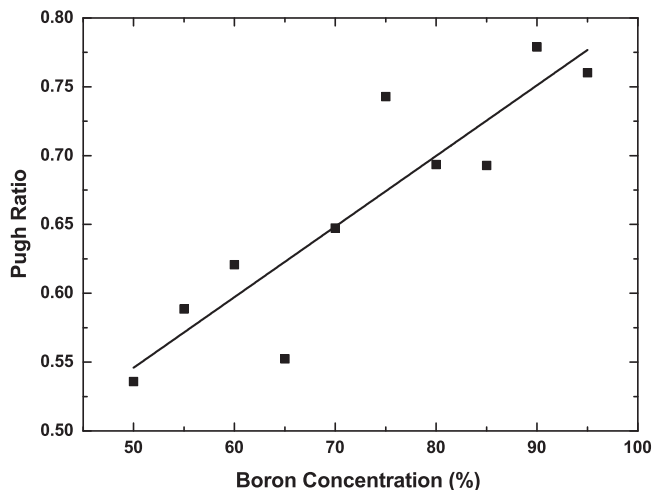


FIGURE 12 Variation of Pugh's ratio as a function of B concentration

carbides, relative to C–C bond and a low sp^3/sp^2 ratio. Because the mechanical properties amorphous diamond strongly depend on the density (or sp^3/sp^2 ratio) and increase with increasing density, high-density a- $B_{50}C_{50}$ material with different sp^3/sp^2 ratios, if they are fabricated under pressure, can show some superior properties, similar to amorphous diamond, for example, superhardness.

Beyond 65% of contents, the materials show the characteristics of both amorphous diamond and a-B because sp^3 hybridization around C atoms is still the dominant one. At 70% B content, ideal pentagonal pyramid motifs ($C-B_5$) develop around C atoms, and hence, the formation of $B_{11}C$ molecules is expected to occur beyond 65% B concentration. Of course, there might be some uncertainties about this composition because of the limitations in the simulations, such as timescale and size of the simulation box.

It is believed that c- B_4C consists of $B_{11}C$ icosahedrons with C–B–C intericosahedral chains rather than B_{12} icosahedrons and C–C–C linear chains.⁵¹ It should be noted here that there exist the C–C–C (not linear chains) angles in the model up to 80% B concentration at which the motifs disappear, whereas a few C–C bonds form in a- B_4C . Consequently, a- B_4C does not have C–C–C linear chains, as proposed for its crystalline counterpart. Additionally, we witness the formation of C–B–C bond angles in the models, but we do not observe the intericosahedral linear C–B–C chains because the $B-C_2$ configuration does not exist in any model.

General trend in the mechanical properties of amorphous materials is to increase with increasing B content. When the amorphous and crystalline phases of materials having 10–20 C% concentrations ($B/C > 4$) are compared, we notice an opposite trend in the mechanical properties.

Namely, the maximum hardness was observed for the stoichiometric composition (c- B_4C), and it is surprisingly decreased for nonstoichiometric B_4C ($B/C > 4$ or $B/C < 4$) compositions. For $B/C > 4$ materials, the decrease was explained by the substitution of the stronger B–C bonds with weaker B–B bonds. For the amorphous phases, on the other hand, we believe that the increase in the CNs and the development of more pentagonal pyramid-like topologies are probably responsible for such an increase in the mechanical properties. Note that twofold-coordination does not exist in the amorphous forms in these composition ranges but in the crystal.

Via various Vickers hardness equations, it is seen that B-rich amorphous materials beyond 70% B content have high hardness. Therefore, these materials can be referred to as hard materials. Moreover, it should be noticed that these amorphous materials show semiconducting properties, and hence, they can offer some potential applications in harsh environments.

5 | CONCLUSIONS


In the current study, for the first time, the structural, electrical, and mechanical characteristics of B-rich amorphous boron carbides (B_xC_{1-x} , $0.50 \leq x \leq 0.95$) have been analyzed by the means of ab initio MD simulations. According to the analyses, the mean CN of B atoms changes between 3.22 and 5.70, whereas that of C atoms changes from 3.46 to 4.30. The materials up to 65% B content carry essentially the characteristic of amorphous diamond, and beyond this content, the materials show the signature of both amorphous diamond and a-B because sp^3 hybridization around C atoms is still the major one in all compositions. The pentagonal pyramid motifs ($C-B_5$) and hence $B_{11}C$ clusters are expected to develop beyond 65% B concentration. There exist the C–C–C angles in the model up to 80% B concentration at which point they vanish. The intericosahedral linear C–B–C chains do not form because $B-C_2$ configuration does not occur in any model. By means of four different Vickers hardness formulas, it is found that some B-rich amorphous materials, specifically after 75% B concentration, have high Vickers hardness, and thus, they can be classified as hard materials. Although the calculated mechanical properties of amorphous boron carbides are fairly comparable with the available data of crystal and amorphous structures, we surely expect some errors in these mechanical properties because of fittings, using empirical equations, and the size of simulation cells. The HOMO–LUMO bandgap calculations expose that all amorphous configurations are semiconductors. All these conclusions are based on 200 atom amorphous configurations, but some of our findings are comparable with the

available data in the literature, and thus, we believe that these amorphous structures generated offer accurate information about the local structure of these compositions. Nevertheless, the finite size effect and the timescale of simulation cannot be ignored, and hence, additional investigations on larger systems using reliable machine learning potentials are essential to expose their microstructures and properties in detail.

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